



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

RECEIVED
MAR 03 2004

In re PATENT APPLICATION of

Norio Hirashita et al.

Serial No.: 09/825,973

Attn: Applications Branch

Filed: April 5, 2001

Attorney Docket No.: OKI.227

For: A STRUCTURE OF A FIELD EFFECT TRANSISTOR HAVING METALLIC
SILICIDE AND MANUFACTURING METHOD THEREOF

CLAIM OF PRIORITY

Honorable Assistant Commissioner for Patents and Trademarks,
Washington, D.C. 20231

Date: September 27, 2002

Sir:

Applicants, in the above-identified application, hereby claim the priority date
under the International Convention of the following Japanese application:

Appln. No. 2000-104733

filed April 6, 2000

as acknowledged in the Declaration of the subject application.

A certified copy of said application is being submitted herewith.

Respectfully submitted,

VOLENTINE FRANCOS, P.L.L.C.

Andrew J. Telesz, Jr.
Registration No. 33,581

12200 Sunrise Valley Drive, Suite 150
Reston, Virginia 20191
Tel. (703) 715-0870
Fax. (703) 715-0877



日 本 国 特 許 庁
JAPAN PATENT OFFICE

F-99ED0291-US
RECEIVED
MAR 03 2004

別紙添付の書類に記載されている事項は下記の出願書類に記載されて
いる事項と同一であることを証明する。

This is to certify that the annexed is a true copy of the following application as filed
with this Office

出 願 年 月 日

Date of Application:

2000年 4月 6日

出 願 番 号

Application Number:

特願2000-104733

出 願 人

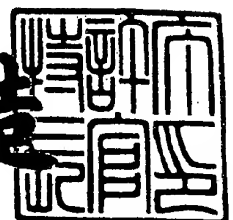
Applicant(s):

沖電気工業株式会社

2001年 4月20日

特許庁長官
Commissioner,
Japan Patent Office

及 川 耕 造





ATTY DOK #: OKI.227

DUE DATE: September 28, 2002

APPLICANT: Norio Hirashita et al.

SERIAL NO.: 09/825,973

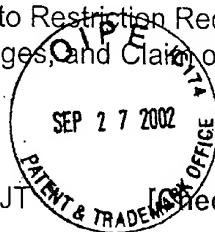
FILING DATE: April 5, 2001

RECEIVED
MAR 03 2004

TITLE: A STRUCTURE OF A FIELD EFFECT TRANSISTOR HAVING
METALLIC SILICIDE AND MANUFACTURING METHOD
THEREOF

RECEIPT OF THE FOLLOWING PAPERS IS ACKNOWLEDGED:

Amendment Transmittal Letter; Response to Restriction Requirement and
Amendment; Version with marked-up changes, and Claim of Priority including
1 document.



DATE: September 27, 2002

ATTY: AJT

Check No. n/a